

# 高透明低抵抗フィルム

## High transparent low resistance film

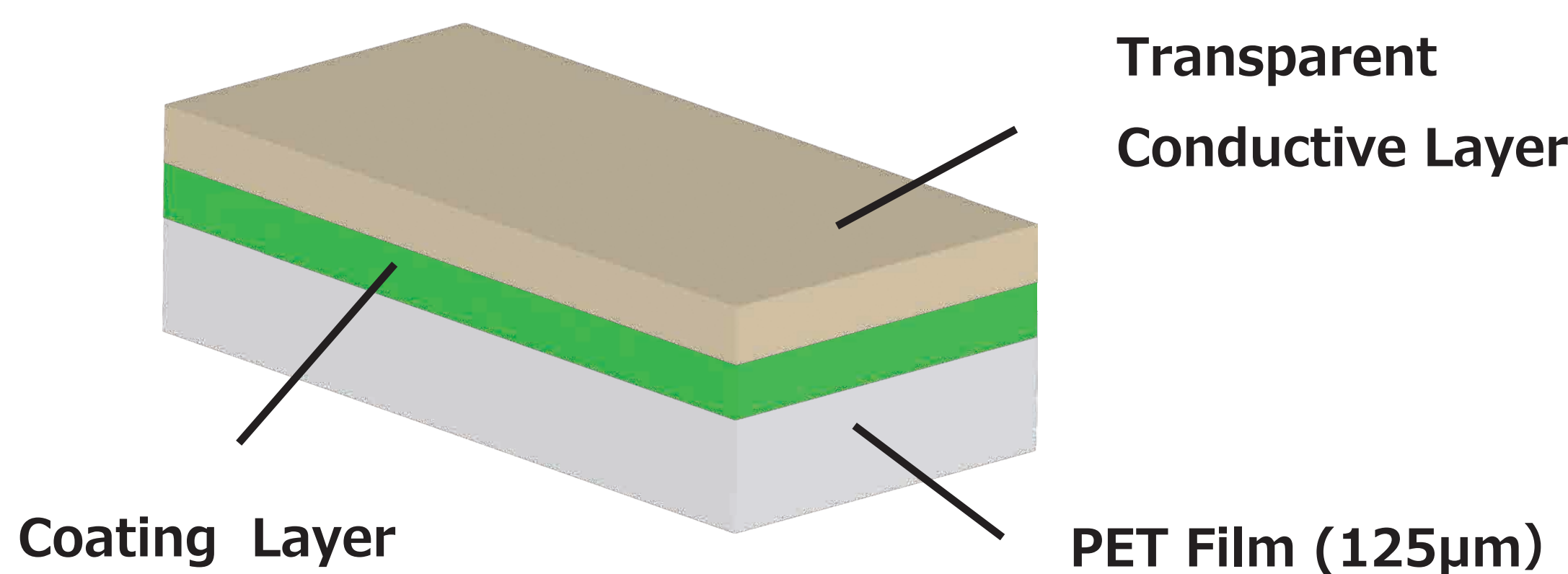
▶ **優れた高透過率をフィルムで実現**

It has excellent high transmittance.

▶ **優れたレーザーエッチング適正**

It has excellent laser etching suitability.

▷ **ELESWAY CL-15 HCR**



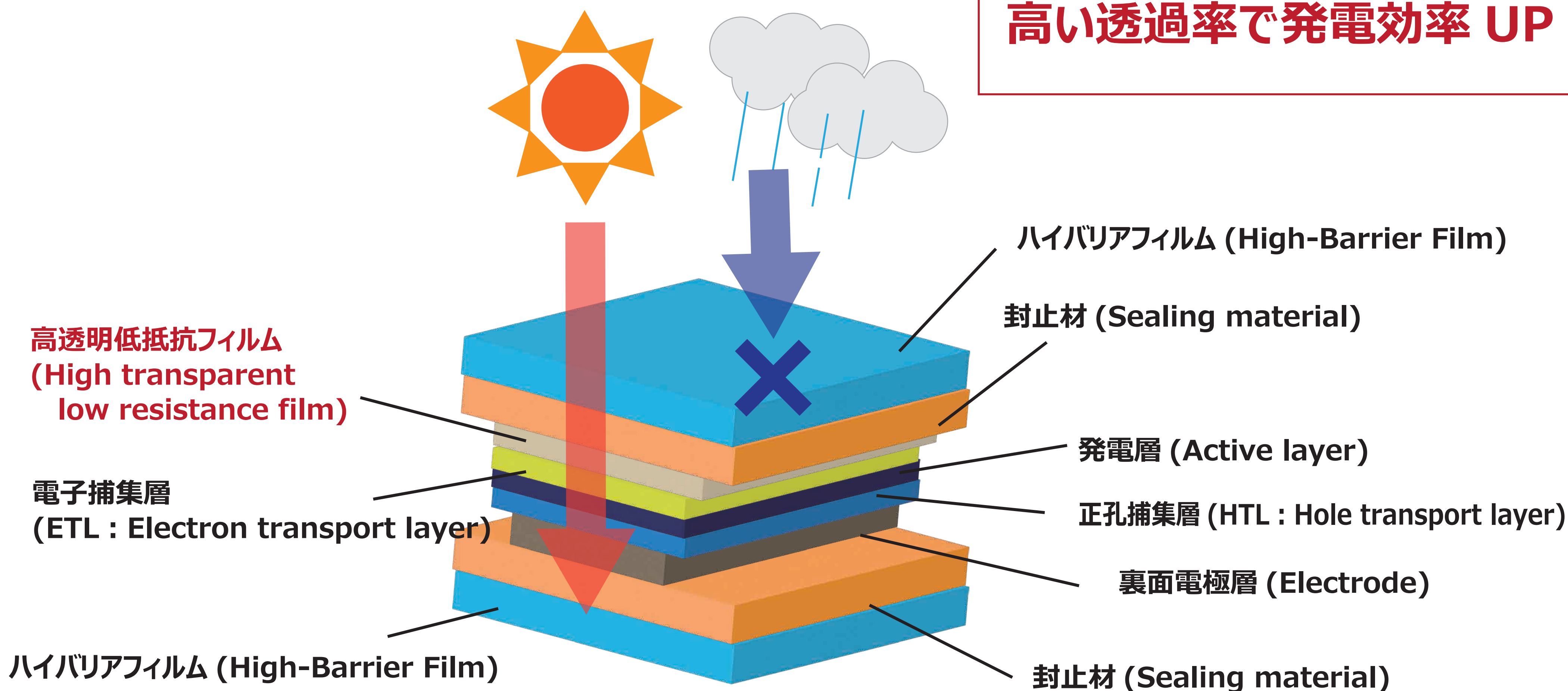
レーザーエッチング加工性

**下地の隆起や透明導電膜のバリが少ない**  
It has less bulges on the base and fewer burrs on the transparent conductive film.

Item	Result	Method
Electrical resistance( $\Omega/\square$ )	<b>14.9</b>	JIS K 7194
Total light transmittance(%)	<b>87.2</b>	JIS K 7361

<フレキシブル太陽電池での部材使用例>

**高い透過率で発電効率 UP**



上記データは一定条件下で求めた測定値であり保証値ではありません。

The above data were obtained from measurements under specific conditions and not guaranteed values.